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### **Organization**

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Institute for Materials Research  
Tohoku University  
2-1-1 Katahira, Aoba-ku, Sendai 980-8577, Japan  
Tel. +81-(0)22-215-2144 Fax. +81-(0)22-215-2482

URL: <http://www.imr.tohoku.ac.jp/>  
E-mail: [pro-adm@imr.tohoku.ac.jp](mailto:pro-adm@imr.tohoku.ac.jp)